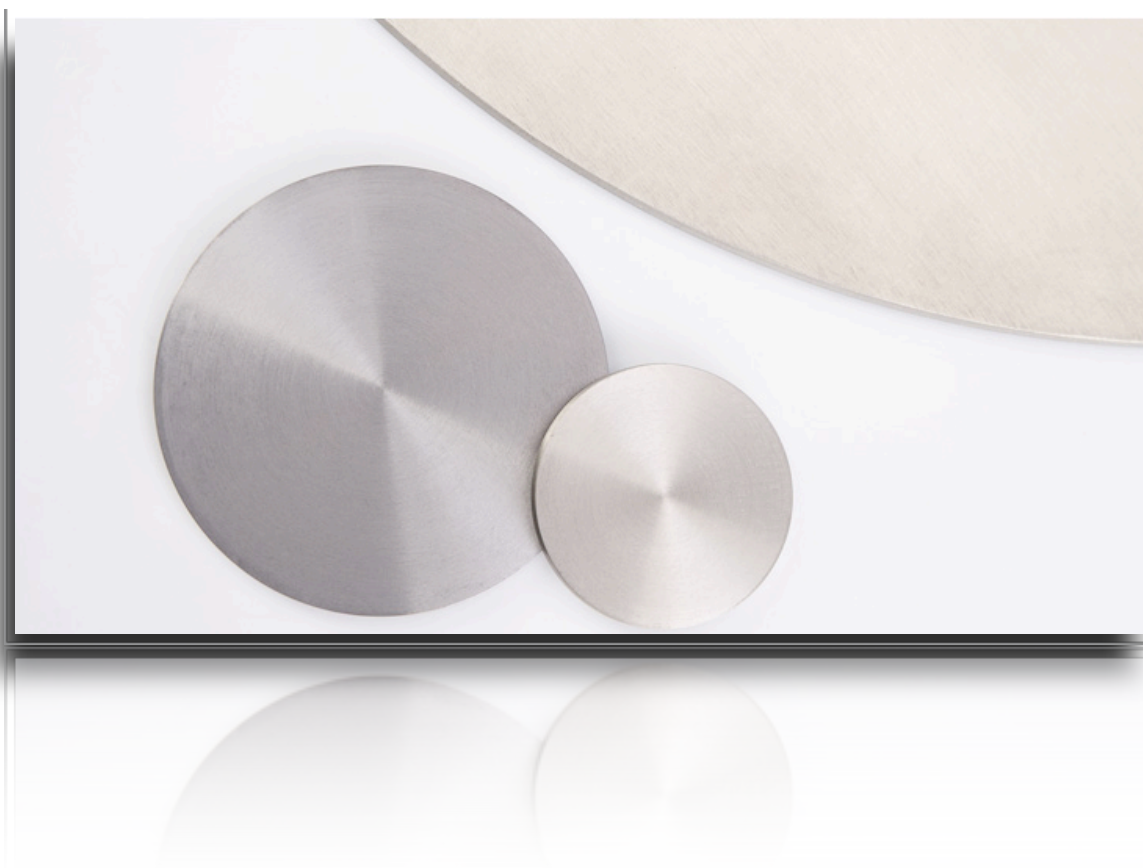




Sputtering Targets



Nitrides

Material	Purity
Aluminum Nitride	99 to 99,999%
Boron Nitride	97,5 to 99,9%
Hafnium Nitride	99,5 %
Niobium Nitride	99,5 %
Silicon Nitride	99,5 %
Tantalum Nitride	99,5 to 99,95%
Titanium Nitride	99,5 %
Zirconium Nitride	99,5 to 99,98%

The materials and sizes listed are available in stock. Other sizes and materials can be prepared upon request.